Supporting Information

Metal-organic framework derived amorphous VOx coated Fe3O4/C hierarchical nanospindle as anode material for superior lithium-ion batteries

Bowen Cong, Yongyuan Hu, Shanfu Sun, Yu Wang *, Bo Wang, Huabin Kong,

Gang Chen *

MIIT Key Laboratory of Critical Materials Technology for New Energy Conversion and Storage, School of Chemistry and Chemical Engineering, Harbin Institute of Technology, Harbin 150001, P. R. China

The supporting information includes 13 figures, 2 tables, and 17 references.

* Corresponding author:

Email: wangyu1012@hit.edu.cn (Yu Wang);

Email: gchen@hit.edu.cn (Gang Chen);



Fig. S1 SEM images of Fe-MOF nanospindles at (a) low- and (b) high-magnification.



Fig. S2 SEM images of Fe-MOF@ V_2O_5 nanospindles at (a) low- and (b) high-magnification.



Fig. S3 SEM images of the Fe_3O_4/C sample at (a) low- and (b) high-magnification.



Fig. S4 The pore size distribution of (a) $Fe_3O_4/C@VO_x$ and (b) Fe_3O_4/C samples.



Fig. S5 Thermo gravimetric analysis (TGA) curves of $Fe_3O_4/C@VO_x$ and Fe_3O_4/C samples at a temperature ramp of 10 °C min⁻¹ in air.



Fig. S6 Charge-discharge curves of (a) $Fe_3O_4/VO_x@C$ and (b) Fe_3O_4/C at the current density of 1000 mA g⁻¹.



Fig. S7 *b*-values evaluation of (a) $Fe_3O_4/C@VO_x$ and (b) Fe_3O_4/C using the relationship between peak current and scan rate.



Fig. S8 TEM images of Fe₃O₄/C@VO_x-1 (the thickness of the VO_x layer is \sim 10 nm)

at (a) high- and (b) low- magnification.



Fig. S9 TEM images of Fe₃O₄/C@VO_x-2 (the thickness of the VO_x layer is ~ 20 nm)

at (a) high- and (b) low- magnification.



Fig. S10 Charge/discharge capacities of $Fe_3O_4/C@VO_x$ sample with different thickness of the VO_x layer is ~ 5 nm ($Fe_3O_4/C@VO_x$), ~ 10 nm ($Fe_3O_4/C@VO_x$ -1) and ~ 20 nm ($Fe_3O_4/C@VO_x$ -2), respectively.



Fig. S11 SEM images of the $Fe_3O_4/C@VO_x$ electrode after 500 cycles at 1 A g⁻¹ current density in (a) low- and (b) high-magnification.



Fig. S12 The Fe₃O₄/C@VO_x electrode after 500 cycles at 1000 mA g^{-1} current density

in (a) TEM and (b) HRTEM images.



Fig. S13 Nyquist plots of fresh cells (inset: equivalent circuit for plot fitting).

Table S1	Comparison	of the LIBs performanc	$e of Fe_3O_4/C(a)VO_x$	electrode material
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Electrode material	Current density (mA g ⁻¹)	Reversible capacity (mA h g ⁻	Cycle number (Times)	Ref.
Hollow Fe ₃ O ₄ /C spheres	200	984	70	[1]
Yolk–Shell Fe ₃ O ₄ @C Composite	1000	750	70	[2]
FeO _x @C yolk-shelled structure	200	790	100	[3]
Graphene- Encapsulated Fe ₃ O ₄ nanoparticles	100	650	100	[4]
Carbon-coated Fe ₃ O ₄ nanospindles	500	530	80	[5]
Fe ₃ O ₄ /C nanotubes	150	600	100	[6]
Fe ₃ O ₄ /C microrods	200	650	100	[7]
Porous Fe ₃ O ₄ /C Microbelts	100	710	50	[8]
3D Hierarchical Fe ₃ O ₄ /Graphene Composites	92.5	609	50	[9]
Mesoporous Fe ₃ O ₄ @C Microcapsules	100	928	50	[10]
Fe ₃ O ₄ /rGO nanorod	500	890	100	[11]
Fe ₃ O ₄ /C Filament Network	100	1278	100	[12]
Hierarchical 3D Fe ₃ O ₄ @porous carbon matrix/graphene	200	1077	100	[13]
Fe ₃ O ₄ @C yolk-shell nanorods	500	954	200	[14]
Fe ₃ O ₄ @C nanosheet	200	1232	120	[15]
Fe ₃ O ₄ /C nanofibers	500	761	300	[16]
Fe ₃ O ₄ microflowers	100	1000	50	[17]
Fe ₃ O ₄ /C@VO _x nanospindles	200	1336	300	Our work

and recently reported $\mathrm{Fe_3O_4}$ and $\mathrm{Fe_3O_4/C}$ based materials in the literature

Table S2 Electrochemical Impedance Parameters of the $Fe_3O_4/C(a)VO_x$ and Fe_3O_4/C						
Samples	$\mathrm{R}_{\mathrm{s}}(\Omega)$	$R_{ct}(\Omega)$				
Fe ₃ O ₄ /C@VO _x	1.96	49.85				
Fe ₃ O ₄ /C	2.41	91.50				

Table S2 Electrochemical Impedance Parameters of the ${\rm Fe_3O_4/C@VO_x}$ and ${\rm Fe_3O_4/C}$

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